

Abstract

Realized is a residue disposal method which makes it possible to efficiently dispose of a residue without causing blockage in a pipe and possible to recover a chlorosilane compound at a higher recovery rate. The present invention is an invention of a residue disposal method of disposing of a residue which is discharged in a reaction product gas processing step included in a trichlorosilane producing method, the residue disposal method including (i) drying the residue so that the residue contains a chlorosilane compound in an amount of not more than 10% by mass and (ii) obtaining a powdered residue.

(Figure 1)